

Detailed Specifications

BDL450 optics	
Glass display	Fused silica glass coated with indium-tin oxide conductive layer and P31 phosphor (ZnS:Ag:Cu-green, 525 nm wavelength)
Angle of acceptance	83° from sample at a distance of 34 mm
Retarding Field Analyzer	Concentric assembly of hemispherical grids
Working distance from sample	10 mm
Grid material	Gold coated St-Steel wire mesh (100 mesh, 81% transparency)
Energy resolution	0.8% at low modulation voltage
Monitoring	4.5" standard viewport
Linear motion	External nipple with bellows up to 150 mm retraction from sample
Integral shutter	Manual shutter driven by a rotary feedthrough
Magnetic shielding	Mu metal cylinder with front cover for maximum attenuation
Assembly	Extreme high vacuum compatibility with stainless steel, high alumina and Au-plated copper alloy materials
Mounting	CF4.5" (DN63CF) double-sided conflat flange with sample distance 145 mm 580mm
Bakeability	Under vacuum, 250°C maximum

Integral miniature electron gun	
Beam energy	LEED: 0-750 eV AES: 0-3000 eV
Beam current	LEED: 2 µA at 100 eV and 0.5 mm beam size AES: up to 100 µA at 3 keV
Beam size	From 1 mm to 250 µm-adjusted by wehnelt potential
Electron source	Tungsten 2% thoriated filament (standard) or single crystal LaB ₆ filament (optional)
Energy spread	0.45 eV (thoriated-tungsten filament)
Overall size	10 mm lens diameter and 80 mm length